**Supporting Information** 

## SnSe Quantum Dots Anchored on Few-layered $Ti_3C_2$ as Anodes for Sodium Ion Batteries with Enhanced Cycle Stability

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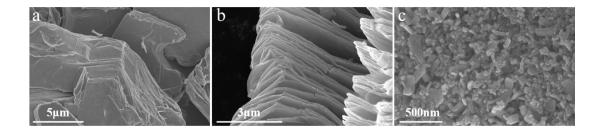
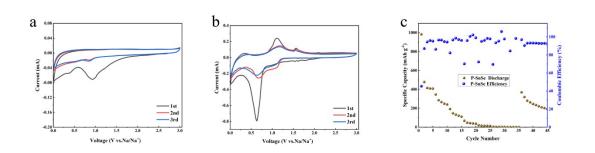


Figure. S1. SEM images of (a)  $Ti_3AlC_2 MAX$ . (b) m- $Ti_3C_2$ . (c) P-SnSe



**Figure. S2.** CV curves of (a)  $f-Ti_3C_2$  and (b) P-SnSe at a scan rate of 0.1 mV s<sup>-1</sup>. (c) Rate performance of P-SnSe electrode.

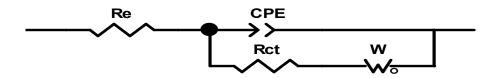


Figure. S3. The equivalent circuit of EIS.

	Re	Rct	CPE-T	CPE-P	W-R	W-T	W-P
	$(\Omega)$	$(\Omega)$	(uF)	(m)	(DW)	(DW)	
SnSe@f-Ti <sub>3</sub> C <sub>2</sub>	6.72	184	1.65E-5	0.71	190.4	0.32	0.32
P-SnSe	5.70	358	3.36E-6	0.86	4221	81.9	0.56

Table S1. Impedance parameters for the equivalent circuits

The relationship between the peak current (i) and the scan rate (v) obeys the power law of

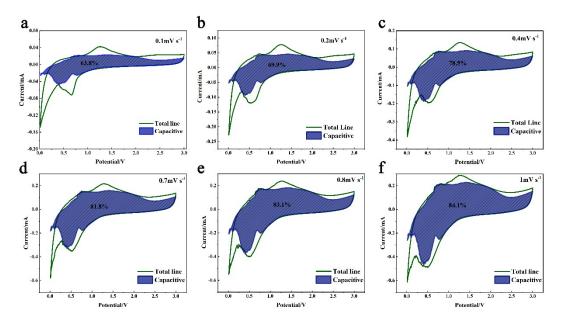
$$i = av^{b}(1)$$

The intrinsic charge storage kinetics of the electrode can be qualitatively reflected by the b value, which is the fitting slope of log (i) to log (v) curve. The b values of 0.5 and 1 correspond to the diffusion-controlled process and the surface-controlled pseudocapacitive reaction, respectively.

In addition, the two contributions at different scan rates can be quantitatively distinguished as follows:

$$i = k_1 v + k_2 v^{1/2} (2)$$

 $k_1 v$  and  $k_2 v^{1/2}$  represent the contributions of pseudocapacitance and diffusion control, respectively.



**Figure. S4.** Separation of capacitive and diffusion-controlled contribution areas at different scanrate: (a) 0.1, (b) 0.2, (c) 0.4, (d) 0.7, (e) 0.8 and 1 mV s<sup>-1</sup> of SnSe@f-Ti<sub>3</sub>C<sub>2</sub>.